

APPLICATION DATA SHEET**Application Information**

Application type:: Regular
Subject matter:: Utility
CD-ROM or CD-R?: None
Title:: PHOTORESIST BASE MATERIAL, METHOD
FOR PURIFICATION THEREOF, AND
PHOTORESIST COMPOSITION

Attorney Docket Number:: 28955.1048
Request for Early Publication:: No
Request for Non-Publication:: No
Total Drawing Sheets::
Small Entity?: No

Applicant Information

Applicant Authority Type:: Inventor
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Correspondence Information

Correspondence Customer Number:: 27890

Representative Information

Representative Customer Number:: 27890

Domestic Priority Information

| Application:: | Continuity Type:: | Parent Application:: | Parent Filing Date:: |
|------------------|-------------------|----------------------|----------------------|
| This application | National Stage of | PCT/JP2003/011137 | 09/01/03 |

Foreign Priority Information

| Country:: | Application Number:: | Filing Date:: | Priority Claimed:: |
|------------------|-----------------------------|----------------------|---------------------------|
| Japan | 2002-300144 | 10/15/02 | Yes |
| Japan | 2003-112458 | 04/17/03 | Yes |